



**NATIONAL STANDARD OF THE
PEOPLE'S REPUBLIC OF CHINA**

GB 51432-2020

**Standard for design of thin film transistor display device glass
substrates manufacture plant
(English Translation)**

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What this standard covers

This standard applies to the design of glass substrate plants for new, rebuilt and expanded thin-film transistor display devices based on the production process of overflow down-draw, float, and notch down-draw glass. In addition to implementing this standard, the factory design of the glass substrate of the thin film transistor display device shall also comply with the current relevant national standards.

Document data

Chinese classification (CCS): P82.

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Standards quoted by this document

GB 50007; GB 50011; GB 50015; GB 50016; GB 50019; GB 50034; GB 50037; GB/T 50050; GB 50052; GB 50057; GB 50058; GB 50068; GB 50073; GB 50084; GB/T 50087; GB 50116; GB 50140; GB 50187; GB 50189; GB 50202; GB 50222; GB 50343; GB 50472; GB 50523; GB 50611